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	Application Number	10/665,128									
TRANSMITTAL	Filing Date	September 22, 2003									
FORM	First Named Inventor	Michael E. Thomas									
(to be used for all correspondence after initial filing	Art Unit	1742									
	Examiner Name	Unknown									
Total Number of Pages in This Submission	Attorney Docket Number	H0003933									
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Firm Jennifer J. Taylor, Ph.D.; Reg Individual	. No. 48,711; Wells St. John P.S.										
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Date January 9, 2004											
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From:

Jennifer J. Taylor, Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)

Wells St. John P.S.

601 W. First Avenue, Suite 1300

Spokane, WA 99201-3828

Dear Sir:

The attached form PTO-1449 is submitted in compliance with 37 CFR § 1.56. Copies of the cited art are included with the exception of U.S. patents and published U.S. applications (1276 Off. Gaz. Pat. Off. 55, 05 August 2003). No admission is made regarding whether all the submitted references are prior art.

Respectfully submitted,

Dated:

By:

lennifer J. Taylor, Ph.D.

Reg. No. 48,711

Form PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY.	DOCKET	NO.							
U0002022									

SERIAL NO. 10/665,128

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APPLICANT
Michael E. Thomas et al.

FILING DATE

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